

Refine Search

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L3 and dopant	10

Database:

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Search History

DATE: Saturday, June 26, 2004 [Printable Copy](#) [Create Case](#)

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	<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>		
<u>L4</u>	L3 and dopant	10	<u>L4</u>
<u>L3</u>	(fluorinated carbons) same (CVD or PECVD or chemical vapor deposition)	70	<u>L3</u>
<u>L2</u>	(perfluorononane or perfluorooctane or perfluoroheptane or perfluorohexane or perfluorotetrane) same (CVD or PECVD or chemical vapor deposition)	4	<u>L2</u>
<u>L1</u>	(perfluorononane or perfluorooctane or perfluoroheptane) same (CVD or PECVD or chemical vapor deposition)	3	<u>L1</u>

END OF SEARCH HISTORY